

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :

Woon-kyung LEE et al. : Attn: Applications Branch

Serial No.: [NEW] :

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For: MASK ROM FABRICATION METHOD

PRELIMINARY AMENDMENT

U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window, **Mail Stop Patent Application**
Crystal Plaza Two, Lobby, Room 1B03
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Sir:

Preliminary to the examination of the above-identified application, please
enter the following amendments and remarks.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims begin on page 4 of this paper.

Remarks begin on page 9 of this paper.